



टाटा मूलभूत अनुसंधान संस्थान
TATA INSTITUTE OF FUNDAMENTAL RESEARCH
भारत सरकार के परमाणु ऊर्जा विभाग की स्वायत्त संस्था एवं समविश्वविद्यालय
(An autonomous institute of the Department of Atomic Energy,
Government of India, and a Deemed University)

सर्वेक्षण संख्या 36 / पी, गोपनपल्ली गांव, सेरिलिंगमपल्ली मंडल, रंगारेड्डी जिला, हैदराबाद - 500 107
Survey No.36/P, Gopanpally Village, Serilingampally Mandal, Ranga Reddy District,
Hyderabad - 500 107

दूरभाष / Telephone: 040 - 20203100 / 3101

वेबसाइट / Website : www.tifrh.res.in

फैक्स / Fax: 040 - 20203105

ईमेल / Email: director@tifrh.res.in

November 19, 2019.

OFFICE ORDER /कार्यालय आदेश- OD-07-2019

Internal Complaints Committee / आंतरिक शिकायत समिति

1. In partial modification and in lieu of Women's Cell, Office Order - OD-03-2018, dated April 23, 2018, TIFR Hyderabad Internal Complaints Committee is here by constituted as follows with immediate effect until further orders:-

Dr. G. Rajalakshmi, raji@tifrh.res.in - Convener
Dr. Monika Vig, mvig@tifrh.res.in
Prof. P. K. Madhu, madhu@tifrh.res.in
Dr. Prasad Perlekar, perlekar@tifrh.res.in
Dr. Pushpita Ghosh, pghosh@tifrh.res.in
Ms. Roopashri R Prasad, roopa@tifrh.res.in
Ms. P. Phani Shilpa, shilpaphani@tifrh.res.in
Ms. Snehasri Cherekar, Lawyer, sneahere1@gmail.com
Prof. Vasanthi Srinivasan (UoH), vsss@uohyd.ac.in / vsss@uohyd.ernet.in

2. This supersedes all previous orders on the subject matter.



(W. Chandrasekhar)
Centre Director

GUIDELINES:

1. The TIFR Hyderabad Internal Complaints Committee has been constituted to protect women against any form of harassment or gender discrimination and to provide a means of redress should such cases arise. The purpose is to allow every employee to pursue their work in a safe and dignified environment. The Internal Complaints Committee also aims to raise awareness regarding issues of bias and discrimination.

2. Any of the members of the Committee listed above may be contacted regarding cases of sexual harassment, discrimination or any other form of bias.

All members of the Committee